

TRANSPARENT SUBSTRATE COMPRISING AN ANTIREFLECTION
COATING

ABSTRACT

Transparent substrate (6) comprising an antireflection coating on at least one of its faces, especially at normal incidence, made from a thin-film multilayer (A), characterized in that the multilayer comprises, in succession:

- a first layer (1), having a refractive index n_1 of between 1.8 and 2.3 and a geometrical thickness e_1 of between 5 and 50 nm;
- a second layer (2), having a refractive index n_2 of between 1.35 and 1.65 and a geometrical thickness e_2 of between 5 and 50 nm;
- a third layer (3), having a refractive index n_3 of between 1.8 and 2.3 and a geometrical thickness e_3 of between 40 and 150 nm; and
- a fourth layer (4), having a refractive index n_4 of between 1.35 and 1.65 and a geometrical thickness e_4 of between 40 and 150 nm.

Figure 2